

**RECEIVED
CENTRAL FAX CENTER**

MAR 08 2006

**PATENT
Attorney Docket No.: ZON-001**

**REPLY UNDER 37. C.F.R. §1.116
EXPEDITED PROCEDURE
GROUP ART UNIT 1753**

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANTS: Chistyakov
SERIAL NO.: 10/065,277 GROUP NO.: 1753
FILING DATE: September 30, 2002 EXAMINER: Rodney G. McDonald
TITLE: High-Power Pulsed Magnetron Sputtering

Mail Stop AF
Commissioner of Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

Amendment and Response After Final

Sir:

The following remarks are responsive to the final Office Action mailed on January 11, 2006 in the above-identified patent application. Consideration of the following remarks, and allowance of the claims, as presented, is respectfully requested. This Amendment and Response is a reply under 37 C.F.R. §1.116. Expedited procedures are requested.

Amendments to the Claims begin on page 2 of this paper.

Remarks are on page 9 of this paper.